WHAT IS CLAIMED IS:

- 1. A ridge waveguide filter having a slow-wave structure comprising an elongate hollow tube, wherein the hollow tube is define by conductive sidewall, and at least a first part of the conductive sidewall periodically protrudes along an elongate direction of the hollow tube to form a plurality of ridges projecting in the hollow tube.
- 2. The ridge waveguide filter of Claim 1, wherein the sidewall is fabricated from metallic materials.
- 3. The ridge waveguide filter of Claim 1, wherein the hollow tube includes a rectangular hollow tube.
- 4. The ridge waveguide filter of Claim I, wherein the hollow tube includes a circular hollow tube.
- 5. The ridge waveguide filter of Claim 1, wherein the ridges are equally spaced from each other.
- 6. The ridge waveguide filter of Claim 1, wherein the ridges are parallel with each other.
- 7. The ridge waveguide filter of Claim 1, wherein each of the ridges has a bottom surface parallel with a second part of the conductive sidewall.
- 8. The ridge waveguide filter of Claim 8, wherein the second part of the conductive sidewall is opposite to the first part of the conductive sidewall.
 - 9. A ridge waveguide filter having a slow structure, comprising: an elongate hollow tube defined by a conductive sidewall;

at least one hollow ridge protruding from the conductive sidewall into the hollow tube and extending along an elongate direction of the hollow tube; and

a plurality of trenches formed in the ridge along the elongate direction.

- 10. The ridge waveguide filter of Claim 10, wherein the conductive sidewall includes a rectangular cross section.
- 11. The ridge waveguide filter of Claim 10, wherein the conductive sidewall includes a circular cross section.
- 12. The ridge waveguide filter of Claim 10, wherein the trenches have a depth the same as a height of the ridge.
- 13. The ridge waveguide filter of Claim 10, wherein the trenches are parallel to each other.
- 14. The ridge waveguide filter of Claim 10, wherein the trenches are equally spaced from each other.
- 15. A method of forming a ridge waveguide filter having a slow-wave structure, comprising:
- a) forming a body portion of an elongate hollow tube, wherein the body portion has an open top;
- b) providing a planar plate having a first surface and a second surface opposite to the first surface;
- c) processing the first surface to form a ridge recessed from the first surface and protruding from the second surface;
- d) processing the second surface to form a plurality of trenches recessed from a top surface of the ridge; and
- e) covering the open top of the body portion by attached the planar plate to the body portion, wherein the second surface of the planar plate faces the body portion.

- 16. The method of forming the ridge waveguide filter of Claim 15, wherein step (a) comprising forming a body portion of an elongate hollow rectangular tube.
- 17. The method of forming the ridge waveguide filter of Claim 15, wherein step (a) comprising forming a body portion of an elongate hollow tube from conductive material.
- 18. The method of forming the ridge waveguide filter of Claim 17, wherein step (b) further comprising providing a conductive planar plate.
- 19. A method of fabricating a ridge waveguide filter having a slow-wave structure, comprising:
- a) forming a conductive body portion of an elongate hollow tube, wherein the body portion has an open top;
 - b) providing a substrate;
 - c) etching the substrate to form a plurality of trenches in the substrate;
 - d) plating the etched substrate with a layer of conductive material; and
 - e) attaching the layer of conductive material with the conductive body portion.
- 20. The method of Claim 19, wherein step (a) comprises providing a silicon substrate.
- 21. The method of Claim 19, wherein step (c) comprises etching the substrate with a plurality of trenches parallel to each other along an elongate direction of the hollow tube.
- 22. The method of Claim 19, wherein step (d) comprises placing the layer of conductive material conformal to an etched surface profile of the substrate.
- 23. A method of maintaining a characteristic impedance of and reducing a size of a waveguide, comprising:
- a) processing a top wall portion of the waveguide to form a ridge extending into the waveguide along an elongate direction of the waveguide; and

- b) further processing the waveguide to form a plurality of ridge segments separated from each other by a gap, so as to effectively introduce a plurality of inductances between the ridge segments, which themselves capacitively couple to a bottom wall of the waveguide, such that the ridge segments and the gaps form a transmission line operating in such a way as to slow a wave propagating down the waveguide.
- 24. The method of Claim 23, wherein step (a) further comprising forming the ridge with a bottom surface parallel to a bottom wall portion of the waveguide.